

Mini Review

# Retracted: Texture of Thin Films of Aluminum Nitride Produced by Magnetron Sputtering

Strunin Vladimir Ivanovich<sup>1</sup>, Baranova Larisa Vasilievna<sup>2\*</sup> and  
Baisova Bibigul Tulegenovna<sup>3</sup>

<sup>1</sup>Doctor of Physics and Mathematics. Sciences, Institute of Radiophysics and Physical Electronics of the Omsk Scientific Center SB RAS, Omsk; Omsk State University named after F.M. Dostoevsky, Omsk, Russia


<sup>2</sup>Ph.D. Tech. Sciences, Institute of Radiophysics and Physical Electronics of the Omsk Scientific Center SB RAS, Omsk; Omsk State University named after F.M. Dostoevsky, Omsk, Russia

<sup>3</sup>Ph.D. Physics and Mathematics Sciences, Institute of Radiophysics and Physical Electronics of the Omsk Scientific Center SB RAS, Omsk; Omsk State University named after F.M. Dostoevsky, Omsk, Russia

More Information

**\*Address for correspondence:**

Baranova Larisa Vasilievna, Ph.D. Tech. Sciences, Institute of Radiophysics and Physical Electronics of the Omsk Scientific Center SB RAS, Omsk; Omsk State University named after F.M. Dostoevsky, Omsk, Russia, Email: baranova@omsu.ru

 <https://orcid.org/0000-0001-9760-5169>

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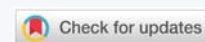
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